Chemicals contained in products

Package-type

Epson Package name； **SOT89-3PIN**
JEITA Package name； **(P-SOT89-3)**
Lead frame plating； **Lead(Pb) Free**
Weight； **0.05** [g] *Note1

Part	Subpart	Subpart weight [mg]	Substance name	CAS No.	Content ※2		Application
					[mg]	[ppm]	
IC Die	IC Die	0.6	Silicon	7440-21-3	0.58	999894	Base material
			Boron	7440-42-8	0.000001	2	Dopant
			Phosphorus	7723-14-0	0.000003	5	Dopant
			Aluminum	7429-90-5	0.00001	20	Metalization
			Arsenic *Note3	7440-38-2	0.000003	5	Dopant
			Fluorine *Note3	7782-41-4	0.000001	2	Dopant
			Titanium *Note3	7440-32-6	0.00001	20	Metalization
			Molybdenum *Note3	7439-98-7	0.00001	20	Metalization
			Tungsten *Note3	7440-33-7	0.00002	30	Metalization
			Cobalt *Note3	7440-48-4	0.000001	2	Metalization
	Stress buffer coat	0.012	Polyimide	-	0.012	1000000	Stress buffer coat *Note4
Package	Die Bonding material	0.034	Silver	7440-22-4	0.028	826087	Base material
			Epoxy resin	-	0.003	86957	Adhesive
			Phenol resin	0	0.003	86957	Adhesive
	Lead Frame Plating	0.70	Tin	7440-31-5	0.68	975000	Solder
			Silver	7440-22-4	0.017	25000	Solder
	Lead Frame	26	Copper	7440-50-8	24.9	945000	Conductor
			Silver	7440-22-4	0.13	5000	Inner lead plating
			Others *Note5	-	1.3	50000	Additive
	Bonding Wire	0.029	Gold	7440-57-5	0.029	1000000	Conductor
	Mold resin	22	Epoxy resin	-	2.9	130000	Base material
			Antimony Trioxide	1309-64-4	0.45	20000	Flame retardant
			Halogenated compound(Brominations epoxy)	-	0.33	15000	Flame retardant
			Silica	60676-86-0/-	17.2	771000	Filler
			Carbon black	1333-86-4	0.067	3000	Coloring agent
			Hardening chemical(ex:Phenol resin)	-	1.3	60000	Hardening chemical
			Organic phosphorous compound	-	0.022	1000	Hardening accelerator

Regarding the information of chemical substances

*Note1 The weight might be somewhat different depending on an individual built-in IC-chip specification like the size etc.
*Note2 Content data are estimated values based on supplier information and intended levels of content in product.
Actual measurements may vary from these values somewhat.
*Note3 Use or not-use of these substances depends on individual built-in IC-chip specification.
*Note4 The stress buffer coat may not be used depending on the individual model.
*Note5 The nickel, zinc, tin, silicon, iron, and the zinc oxide are included for the Cu type. And the carbon, silicon, and manganese are included for 42alloy type.